# Large Scale, Homogeneous SOFC Cathode Infiltration by Single Step, Ultrasonic Spraying Process

Shiwoo Lee<sup>1),2)</sup>, Regis P. Dowd Jr.<sup>1),3)</sup>, Kirk Gerdes<sup>1)</sup> <sup>1)</sup>National Energy Technology Laboratory, U.S. Department of Energy, <sup>2)</sup>AECOM, <sup>3)</sup>University of Kansas (ORISE)

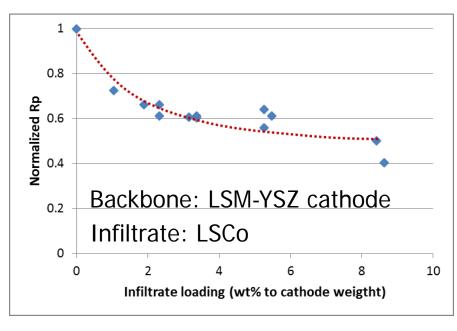
## Large scale, Homogeneous Infiltration

Limitations of conventional manual infiltration process in applications for large scale, commercial manufacturing process:

- □ Inhomogeneity: Conventional manual process is unable to control spatial homogeneity of catalyst distribution and inefficient in terms of cost and manufacturing time.
- □ **Multiple steps:** It requires multiple infiltration (> 4 times) and heating cycles to 850C to deposit a sufficient amount of electrocatalyst at the cathode active layer while preventing agglomeration at the cathode surface.

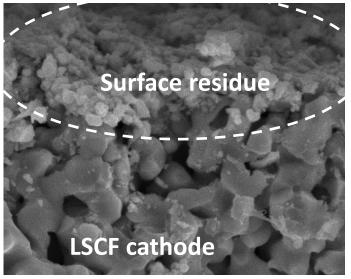
**Motivation:** Minimum number of processing steps are required for industry's commercialization application. The goal of this research is to develop a single step infiltration process to introduce required amount of electrocatalyst to large scale SOFC cathode, thereby greatly reduce the overall time and cost.

## Single-step Infiltration



Threshold infiltrate mass: Polarization resistance decreases with infiltrate loading, and a minimum threshold infiltrate mass is required for "full" activation. The threshold amount of infiltrated electrocatalyst is 6-8 wt% of a baseline cathode.

Single step infiltration means an infiltration process that does not require interspersed heattreatment before infiltrating the full threshold mass of catalyst materials in the porous electrode.





## Chemical Approach

The following items comprise the essential components of the present research.

### **Surfactant**

- Reduce surface tension and improve wettability
- CMC (Critical micelle concentration): Surfactant concentration above which additional surfactant generates micelles instead of solvating the solute.
  - Triton X-100 (Octylphenol ethoxylate): 0.23 mM
  - SDBS (Sodium dodecyl benzene sulfonate): 1.6 mM
  - SDS (Sodium dodecyl sulfate): 8.0 mM

### **Chelating Agent**

- Complex with metal ions and assist with forming correct catalyst phase upon calcination
- Molar fraction of the chelating agent (**citric acid** in this study) affects concentration and viscosity of solution, and ultimately residual infiltrate mass after calcination.

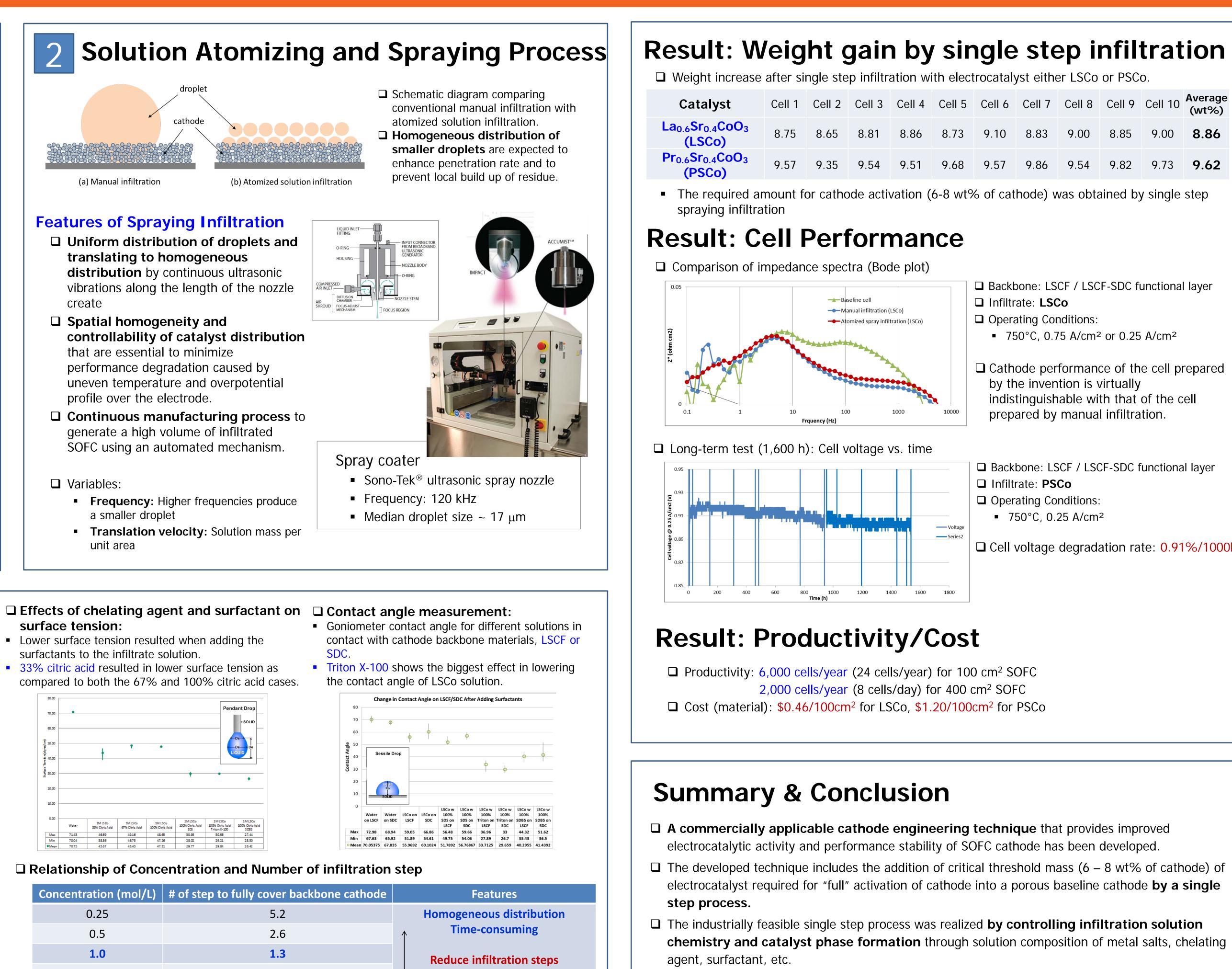
### **Concentration**

- Determine (1) residual amount of electrocatalyst after calcination, which directly correlated with the number of infiltration-calcination step
- Determine (2) degree of solution penetration into porous electrode by affecting solution viscosity
- **1 M solution** was selected. (cf. saturation concentration = 1.5 M)

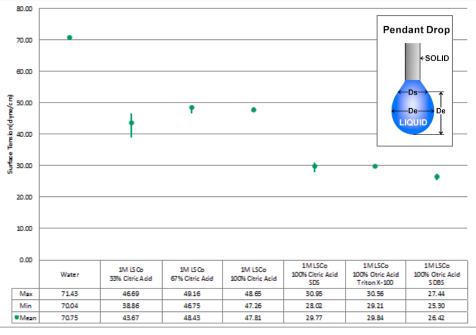
### **Pretreatment (surface energy control)**

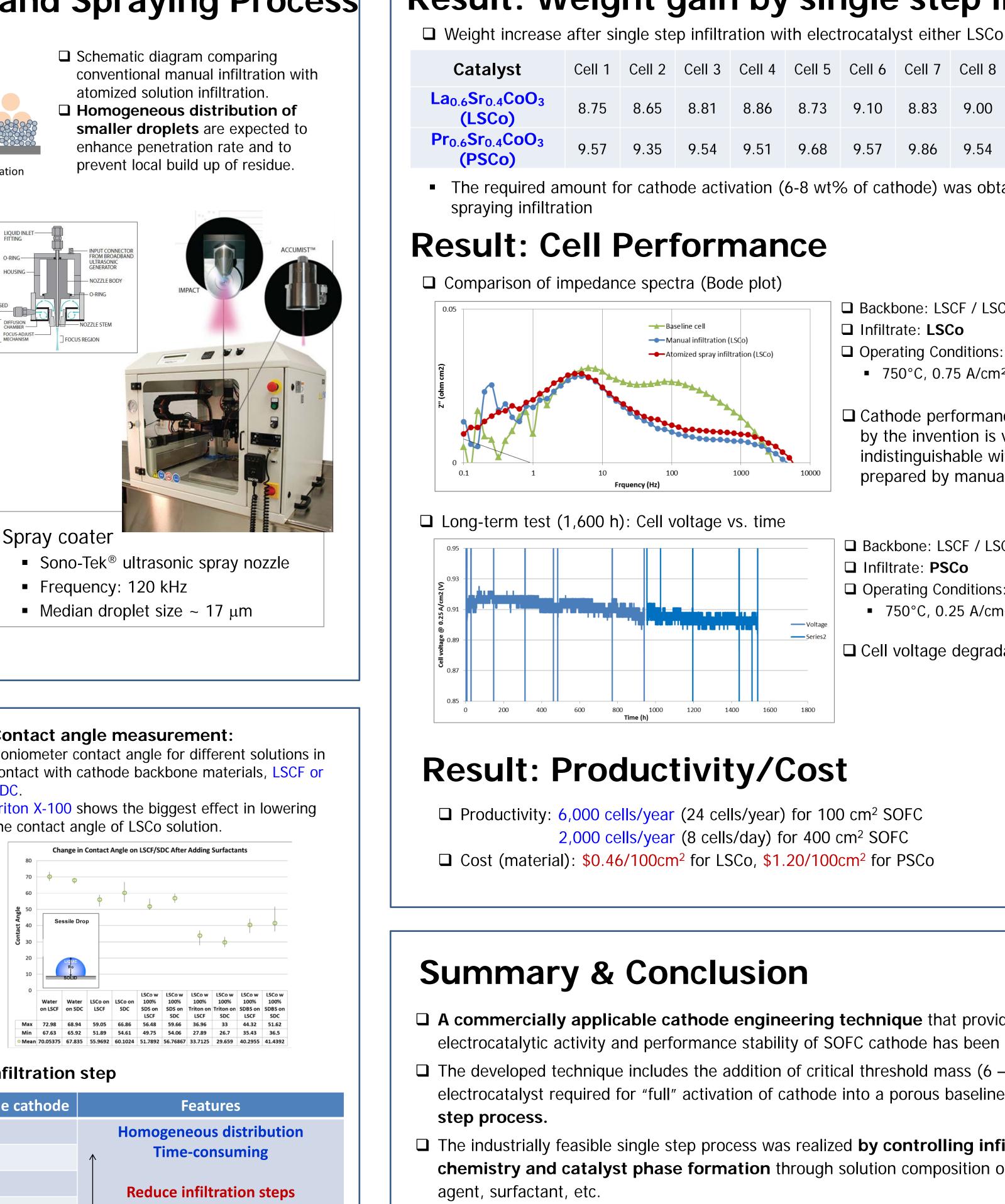
- Chemical method: Surface treatment with polar or non-polar solution
- Thermal method: Heat-treatment at mild temperatures
- Plasma method





- 33% citric acid resulted in lower surface tension as

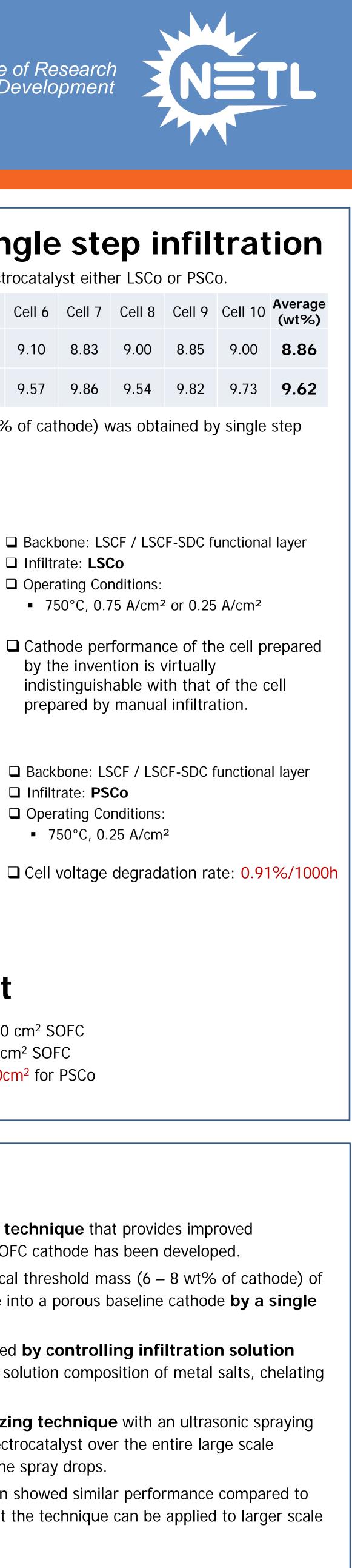




Concentration (mol/L)	# of step to fully cover backbone cathode	Features
0.25	5.2	Homogeneous distribution Time-consuming Reduce infiltration steps Viscous solution
0.5	2.6	
1.0	1.3	
1.3	1.0	

### **Temperature effect**

- Solution heating (claimed in US Patent App. 20080193803): Negative effect by forming highly viscous solution that cannot penetrate porous cathode
- Substrate heating: Effective in lowering surface energy of substrate, but simultaneously accelerate solvent evaporation rate



- In addition to chemistry control, the solution atomizing technique with an ultrasonic spraying system facilitates uniform distribution of infiltrated electrocatalyst over the entire large scale cathode by generating soft, highly focused beam of fine spray drops.
- □ The button cells prepared by the single-step infiltration showed similar performance compared to the ones prepared by manual infiltration, implying that the technique can be applied to larger scale cells without sacrificing performance.

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